

<b>Notice of References Cited</b>	Application/Control No. 10/074,128	Applicant(s)/Patent Under Reexamination BOWER ET AL.	
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	C	US-2001/0023986	09-2001	Mancevski, Vladimir	257/741
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	N	WO 99/65821 A1	12-1999	PCT	Ren et al.	-
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	V	Cui et al., "Aligned Carbon Nanotubes Via Microwave Plasma Enhanced Chemical Vapor Deposition", Mat. Res. Soc. Symp. Proc. Vol.593, pages 39-44, July 2000
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.